Hydrogen Peroxide, 30% CMOS (Stabilized)





Material No.: 2190-23 Batch No.: 0000155109 Manufactured Date: 2016/09/29

Expiration Date: 2018/03/30

Certificate of Analysis

| Test | Specification | Result |
|--|---------------|--------|
| Assay (H ₂ O ₂) | 30.0 - 32.0 % | 31.6 |
| Color (APHA) | <= 10 | 5 |
| Free Acid (µeq/g) | <= 0.2 | < 0.2 |
| Residue after Evaporation | <= 10 ppm | 2 |
| Ammonium (NH ₄) | <= 3 ppm | < 3 |
| Chloride (CI) | <= 0.2 ppm | < 0.2 |
| Nitrate (NO ₃) | <= 2 ppm | < 2 |
| Phosphate (PO ₄) | <= 1 ppm | < 1 |
| Sulfate (SO ₄) | <= 3 ppm | < 3 |
| Trace Impurities - Aluminum (AI) | <= 70.0 ppb | < 5.0 |
| Arsenic and Antimony (as As) | <= 10 ppb | < 2 |
| Trace Impurities - Barium (Ba) | <= 20.0 ppb | < 1.0 |
| Trace Impurities - Beryllium (Be) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Bismuth (Bi) | <= 20.0 ppb | < 10.0 |
| Trace Impurities - Boron (B) | <= 10.0 ppb | < 5.0 |
| Trace Impurities - Cadmium (Cd) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Calcium (Ca) | <= 50.0 ppb | 9.3 |
| Trace Impurities - Chromium (Cr) | <= 20.0 ppb | 1.6 |
| Trace Impurities - Cobalt (Co) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Copper (Cu) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Gallium (Ga) | <= 20.0 ppb | < 1.0 |
| Trace Impurities – Germanium (Ge) | <= 10.0 ppb | < 10.0 |
| Trace Impurities - Gold (Au) | <= 10.0 ppb | < 5.0 |
| Heavy Metals (as Pb) | <= 500 ppb | < 250 |

Material No.: 2190-23 Batch No.: 0000155109

| Test | Specification | Result |
|-------------------------------------|-------------------|--------|
| Trace Impurities - Iron (Fe) | <= 50.0 ppb | 4.1 |
| Trace Impurities - Lead (Pb) | <= 10.0 ppb | < 10.0 |
| Trace Impurities - Lithium (Li) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Magnesium (Mg) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Manganese (Mn) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Molybdenum (Mo) | <= 10.0 ppb | < 5.0 |
| Trace Impurities - Nickel (Ni) | <= 10.0 ppb | < 5.0 |
| Trace Impurities - Niobium (Nb) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Potassium (K) | <= 600.0 ppb | 253.3 |
| Trace Impurities - Silicon (Si) | <= 100.0 ppb | 24.3 |
| Trace Impurities - Silver (Ag) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Sodium (Na) | <= 100.0 ppb | < 5.0 |
| Trace Impurities - Strontium (Sr) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Tantalum (Ta) | <= 10.0 ppb | < 5.0 |
| Trace Impurities - Thallium (TI) | <= 50.0 ppb | < 5.0 |
| Trace Impurities - Tin (Sn) | 190.0 - 500.0 ppb | 287.1 |
| Trace Impurities - Titanium (Ti) | <= 10.0 ppb | < 5.0 |
| Trace Impurities - Vanadium (V) | <= 10.0 ppb | < 1.0 |
| Trace Impurities - Zinc (Zn) | <= 50.0 ppb | < 1.0 |
| Trace Impurities - Zirconium (Zr) | <= 10.0 ppb | < 1.0 |
| Particle Count - 0.5 µm and greater | <= 100 par/ml | 7 |
| Particle Count - 1.0 µm and greater | <= 10 par/ml | < 1 |

For Microelectronic Use

Country of Origin: US

Packaging Site: Paris Mfg Ctr & DC



Phillipsburg, NJ 9001:2008, 14001:2004, FSSC 22000
Paris, KY 9001:2008
Mexico City, Mexico 9001:2008
Deventer, The Netherlands 9001:2008, 14001:2004, 13485:2003
Gliwice, Poland 9001:2008, 13485:2012
Selangor, Malaysia 9001:2008
Dehradun, India, 9001:2008, 14001:2004, 13485:2003
Mumbai, India, 9001:2008
Panoli, India 9001:2008

